

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE



Applicant: John T. Moore and
David L. Chapek

§ Group Art Unit: 2811

Serial No.: 09/496,794

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Filed: February 2, 2000

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For: Trench Isolation for
Semiconductor Devices

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Examiner: D. Owens

Atty. Dkt. No.: MICT-0005-
D1-US

Commissioner for Patents
Washington DC 20231

REPLY TO PAPER NO. 3

Sir:

In response to the office action mailed March 28, 2001,
reconsideration is respectfully requested in view of the
following remarks:

Remarks

The pending claims were rejected under § 103 over the patent
to Fazan that is assigned to Micron Technology, Inc. as is the
present application. Moreover, the Fazan patent issued less than
a year before the filing date of this application. Therefore
under 35 U.S.C. § 103(c), the Fazan patent cannot be used to
fashion a § 103 rejection of the present application. See
M.P.E.P. § 2146.

Date of Deposit: 4/19/01
I hereby certify under 37 CFR 1.8(a) that this correspondence is
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Lisa O'Sullivan

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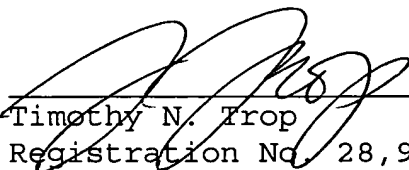
2811
#4 Reconsideration
4-2701

Therefore reconsideration of the rejection based on Fazan is respectfully requested.

Date: _____

4/19/01

Respectfully submitted,



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